

--19. The CVD apparatus according to claim 17, wherein an electrode for plasma generation is disposed in said chamber.--

--20. The CVD apparatus according to claim 18, wherein an electrode for plasma generation is disposed in said chamber.--

• • • R E M A R K S • • •

By the present Preliminary Amendment, the specification, claims and abstract have been revised to more clearly describe applicant's invention in accordance with the requirements of 35 U.S.C. § 112.

Care has been taken so as to avoid the addition of new matter in the specification, claims and abstract.


Entry of the present Preliminary Amendment prior to the examination of the application is respectfully requested.

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Respectfully submitted,

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